

Abstract Submitted  
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**The Structure, Stability and Origin of beta-Phase Ta** AIQIN JIANG<sup>1</sup>, TREVOR TYSON<sup>2</sup>, LISA AXE<sup>3</sup>, New Jersey Institute of Technology — Tantalum thin films exhibit two crystalline phases, bcc ( $\alpha$ -phase, the bulk structure of tantalum) and metastable tetragonal  $\beta$ -phase, which differ in both mechanical and electrical properties. In order to understand the stability of the  $\beta$  phase and the origin of the  $\beta$ -to- $\alpha$  phase transformation, molecular dynamics simulations have been performed on tantalum clusters. Molecular dynamics simulations show that the  $\beta$  phase is stable with a very high melting point. No phase transformation was observed for pure  $\beta$ -Ta clusters from room temperature to the melting point. Simulations of Ta clusters with mixed  $\alpha$  and  $\beta$  phases revealed that inclusion of a small  $\alpha$ -Ta cluster inside a  $\beta$ -Ta cluster induces  $\beta$  to bcc transformation at a temperature far below its melting point, depending on the cluster size and  $\alpha$  to  $\beta$  atom ratio. These results suggest that the observed  $\beta$  to bcc transformation results from the presence of small  $\alpha$ -phase grains within the  $\beta$ -Ta films. The growth of  $\beta$ -Ta on substrate as a result of strain is being evaluated.

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